

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of :

Ki-Hwan PARK et al. :

Serial No. [NEW] :

Filed: October 30, 2003 :

METHOD OF AND APPARATUS FOR CLEANING SEMICONDUCTOR
WAFERS

PRELIMINARY AMENDMENT

U.S. Patent and Trademark Office
2011 South Clark Place
Customer Window, **Mail Stop Patent Application**
Crystal Plaza Two, Lobby, Room 1B03
Arlington, VA 22202

Sir:

Prior to the examination of the above-identified application, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins of page 2 of this paper.

Remarks begin on page 6 of this paper.